



Standing Up an Academic MPW to Enable IC Design Education

LaMar Hill

President's Office

 **NY** CREATES

Supporting NY, US & Global Semiconductor Ecosystem

Douglas Grose Ph.D.
Chairman

Primary Stakeholders

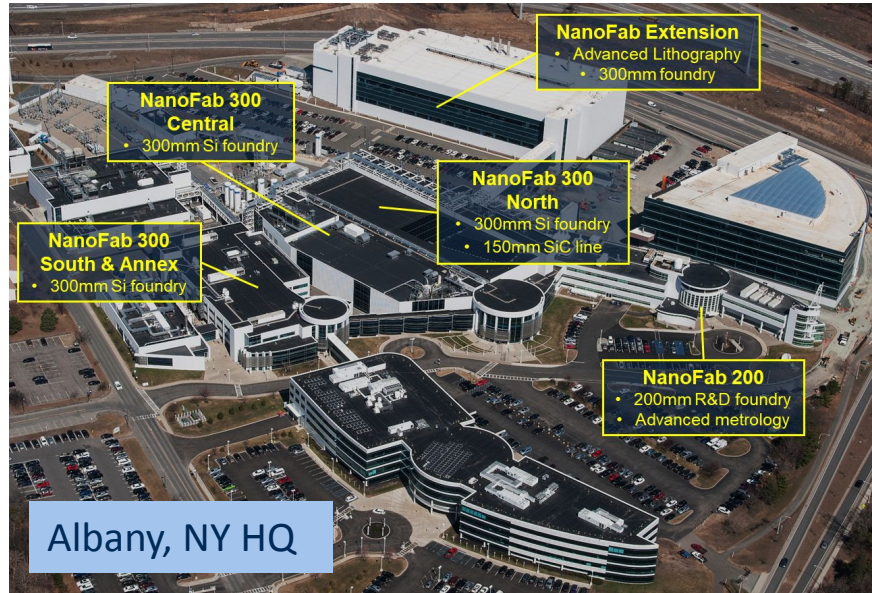
- New York State
- US Government
- Industry
- SUNY RF

ONGOING PROGRAMS

- NY CREATES-CSR 300mm R&D FOUNDRY
- APPLIED MATERIALS META CENTER
- TEL TECHNOLOGY CENTER AMERICA
- NY PEMC¹ (CREE, DANFOSS)
- IBM AI HARDWARE CENTER
- ROCHESTER TAP² FACILITY
- AIM PHOTONICS

1: New York Power Electronics Manufacturing Consortium

2: Rochester Test, Assembly, & Packaging



- Greater than \$15B Investment
- 2,700 Staff, Scientists & Engineers
- 164k ft² Clean Room Space
- More than 200 Industry Partners
- \$350M/year Operating Budget
- \$150M/year Cap-Ex Equipment Budget



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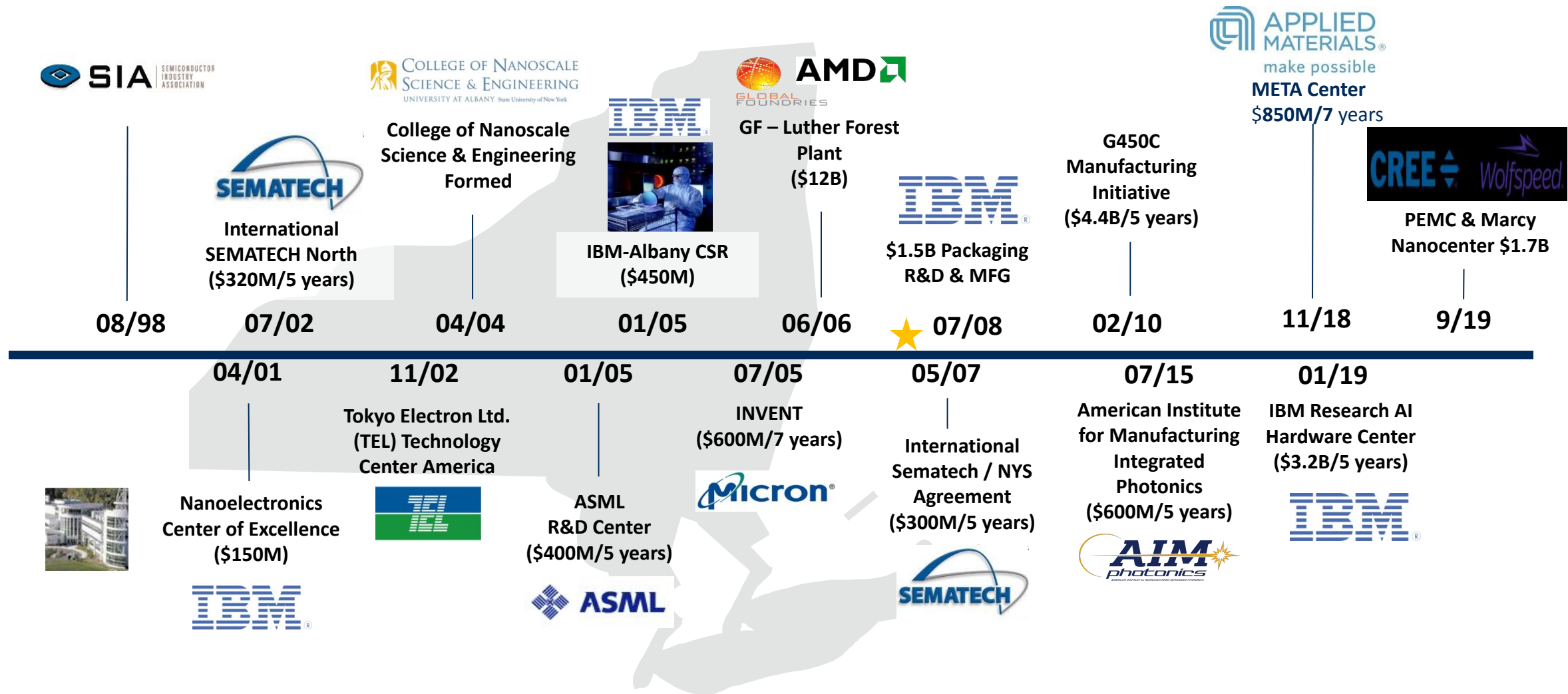
Primary Services

- Technology R&D
- Economic Development & Commercialization
- Workforce Development

ONGOING R&D

- AI/NEUROMORPHIC COMPUTING
- INTEGRATED PHOTONICS
- QUANTUM TECHNOLOGIES
- EMERGING MEMORY PLATFORMS
- POWER ELECTRONICS
- NANOBIO DEVICES
- HETEROGENEOUS INTEGRATION

Major Initiatives Timeline





The Grand Workforce/Talent Challenges

- Severe lack of Qualified Construction Workers
- Semi Industry's "Career Path Appeal" for Chemists, Chemical Eng, EHS Eng, Mech Eng., Electrical Eng., etc.
- Disconnect between Industry & Educational Systems
- Academic Silo-ing
- Diverse Regional Workforce Dev. Systems
- **Greatest Challenge Filling the Seats**

Academic EE & IC Design Education & Research Efforts in NY & US

New York University Partners

- Cornell University
- Columbia University
- RIT
- URochester
- RPI
 - CCNI
- NYU
- Clarkson University
- Westpoint-The Military Academy
- Syracuse University
- SUNY
 - Poly/CNSE, U Buffalo, Stony Brook, Binghamton
- **NY Output of EE with Design Focus 800/year**

Traditional US University Relationships

- MIT
- UCSB
- U Arizona
- Purdue
- UT Knoxville
- U Maryland

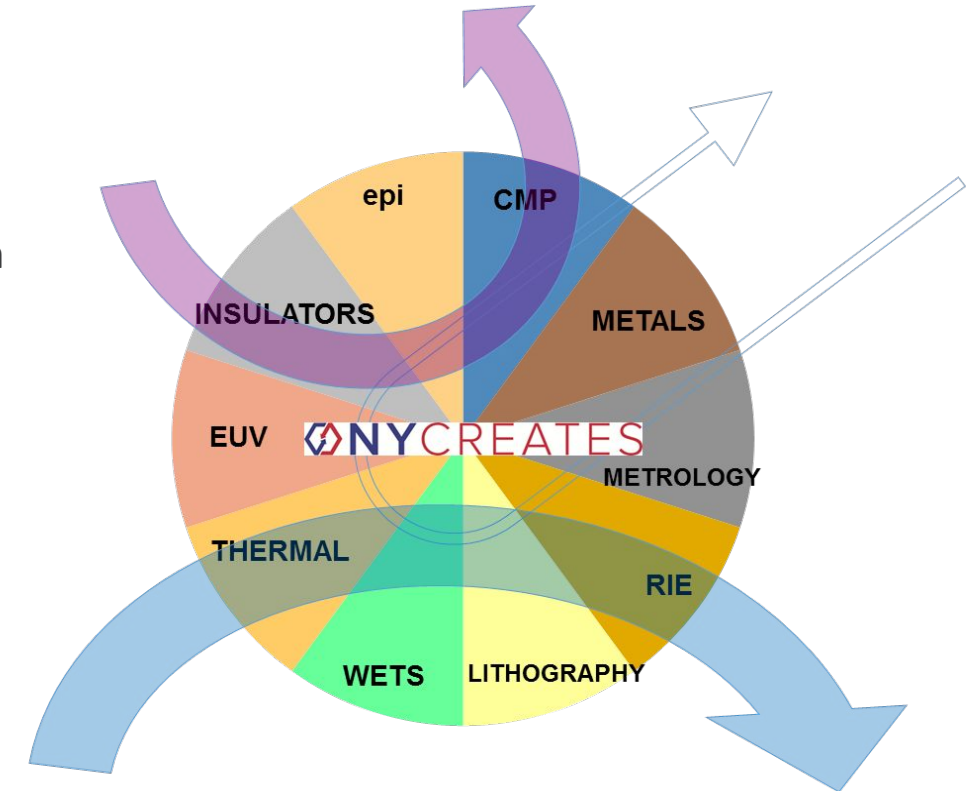
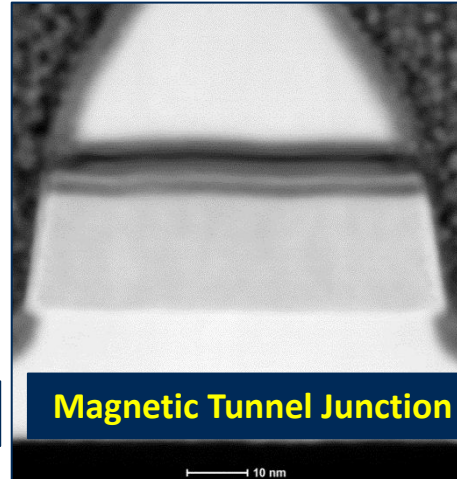
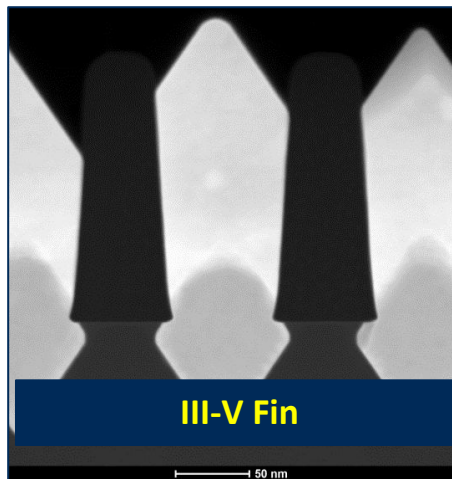
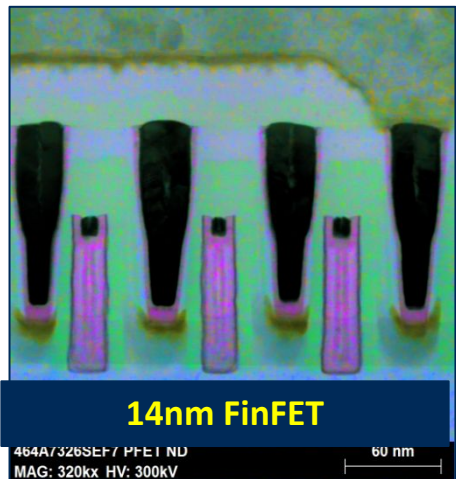
300mm R&D Fab

□ Industry technology, equipment and supply chain leaders leverage the state-of-art fab

□ 65 nm Base Full Flow, Advance nodes available downstream, R&D on 7nm to 2nmga

□ NY CREATES team provides:

- Process development across all sectors
- Integration and data analysis
- Includes Test Assembly & Packing along with Heterogeneous Integration
- MPW Management
- Operational execution
- Flexible work scope



NYCREATES

Organizational Experience with MPW Runs

- There has been a Photonic IC MPW in place for 5 years using base 65nm IBM initiated process with CMOS PDK.
- A PIC PDK was developed and for first 2-years Aggregation and admin was done by MOSIS.
- Last 3-years entire effort done by in-house engineering staff
- Typically 3-4 MPW runs are completed each year.

Standing Up a NY CREATES Academic MPW

- Vision

- Start with 65nm full Flow with open PDK
- Up to 20 Universities get a tile allowing multiple designs for each reticle-mask set
- NY CREATES to complete aggregation/tape out with maximum learning for all.
- Expect multi-semester program with Fab effort, evaluation, test in last semester of program
- Initial program would be Front end Si Run
- Advanced Packaging and Test added on.
- Fund Raising and Program development with Founding Universities Jan-Sept. 2022

New Thrusts in IC Design

- Academic MPW Summit spring 2022
- Partnership with Synopsys, Siemens-Mentor Graphics, Cadence, ARM
 - Access to IP Library
- Joint University Delivered IC Design Curriculum
 - Certificate Programs
- Design Center Of Excellence for RF, DoD, Bio Chips, Autonomous Ops and Energy Chips at Primary Research Universities
- Partner with Industry through SRC & SEMI
- Internships & Engineering Co-ops a MUST

Get Involved!

- Your Input is much needed! We are open to ideas!
- Let's re-invigorate the ubiquitous IC Design Cycle

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